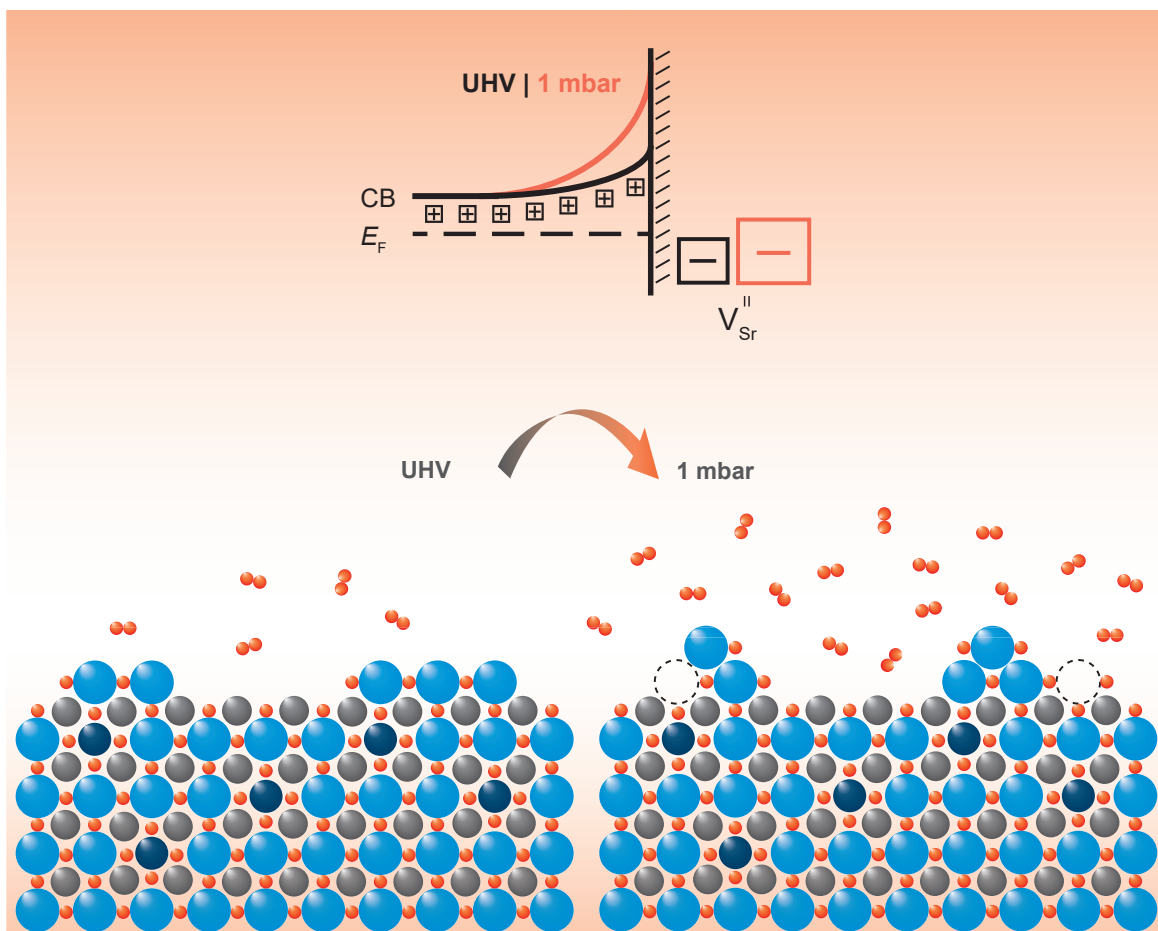




Chemical control of the electrical surface properties of *n*-doped transition metal oxides

Michael Tobias Andrä

Information

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